Chad M Huard

List of Publications by Year in descending order

Source: https://exaly.com/author-pdf/6631677/publications.pdf

Version: 2024-02-01

9 papers

343 citations

8 h-index 1588992 8 g-index

9 all docs 9 docs citations

times ranked

9

481 citing authors

#	Article	IF	CITATIONS
1	Plasma etching of high aspect ratio features in SiO2 using Ar/C4F8/O2 mixtures: A computational investigation. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 2019, 37, .	2.1	64
2	Consequences of atomic layer etching on wafer scale uniformity in inductively coupled plasmas. Journal Physics D: Applied Physics, 2018, 51, 155201.	2.8	18
3	Transient behavior in quasi-atomic layer etching of silicon dioxide and silicon nitride in fluorocarbon plasmas. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 2018, 36, .	2.1	45
4	Role of neutral transport in aspect ratio dependent plasma etching of three-dimensional features. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 2017, 35, .	2.1	44
5	Abnormal Multiple Charge Memory States in Exfoliated Few-Layer WSe ₂ Transistors. ACS Nano, 2017, 11, 1091-1102.	14.6	42
6	Investigation of feature orientation and consequences of ion tilting during plasma etching with a three-dimensional feature profile simulator. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 2017, 35, .	2.1	34
7	Origins of aspect ratio dependent etching in plasma materials processing. , 2016, , .		O
8	Highly stable and stretchable graphene–polymer processed silver nanowires hybrid electrodes for flexible displays. Journal of Materials Chemistry C, 2015, 3, 1528-1536.	5.5	56
9	ITOâ€Free, Compact, Color Liquid Crystal Devices Using Integrated Structural Color Filters and Graphene Electrodes. Advanced Optical Materials, 2014, 2, 435-441.	7.3	40